



1752

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Date: February 7, 2002

A. Afzali-Ardakani et al.

Group Art Unit: 1752

Serial No.: 09/685,414

Examiner: C. Hamilton

Filed: October 10, 2000

Docket No.: YOR920000360US2

For: HIGH SENSITIVITY CROSSLINKABLE PHOTORESIST COMPOSITION,  
BASED ON SOLUBLE, FILM FORMING DENDRIMERIC CALIX[4]ARENE  
COMPOSITIONS METHOD AND FOR USE THEREOF

Assistant Commissioner for Patents  
Washington, D.C. 20231

**APPOINTMENT OF ASSOCIATE POWER OF ATTORNEY**

Sir:

Please recognize Thomas A. Beck, Reg. No. 20,816, as associate attorney, with full power to prosecute, inspect, and transact all business concerning the above-identified application, including the filing of amendments, continuation applications, divisional applications and continuation-in-part applications.

Please direct all official communications to:

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Respectfully submitted,

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